

Micro-structuring of optical surfaces

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Bespoke optical components / surfaces

- Manufacture of optics and the integration of optics and electronics increasingly important
- Traditional optical manufacture techniques
 - suitable for high volumes
 - spherical and planar surfaces
 - not suitable for low volume, aspherical, customised components
- Lasers ideal for highly flexible structuring on a sub-micron scale but resultant surfaces can be significantly scattering for optical wavelengths
 - However by control of laser wavelength and pulse length develop processes for the manufacture of optical components

Laser machining of precision surfaces – optimal pulse length?

Nanosecond laser machining

- widely used for machining of various materials
- Typical features sizes
- Cracking problems

Ultrafast (femtosecond)

- Metals

- Absorption length
- Delay in transfer of energy (electron-phonon coupling)
- Subsequent cracking
- Also need to consider electron thermal diffusion

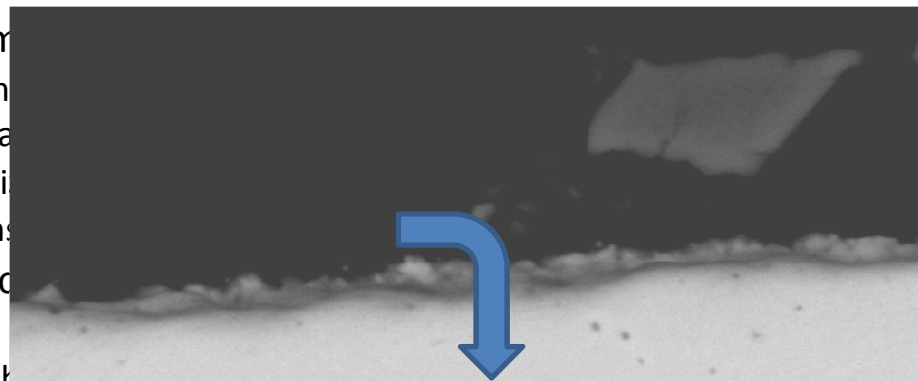
- Transparent materials

- Linear and non-linear absorption
- Emission of photo-electrons
- Coulomb explosion

- Impact of wavelength:

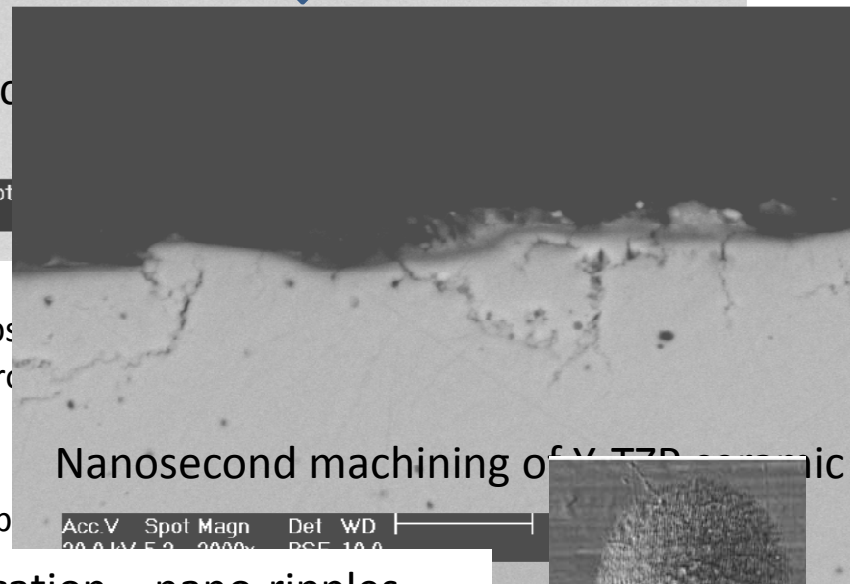
- uv wavelengths achievable

- Further complication – nano-ripples



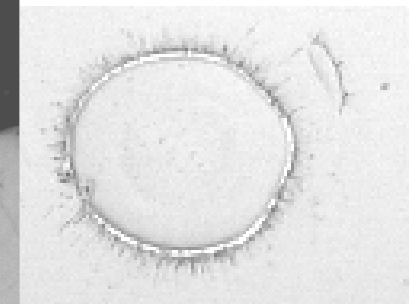
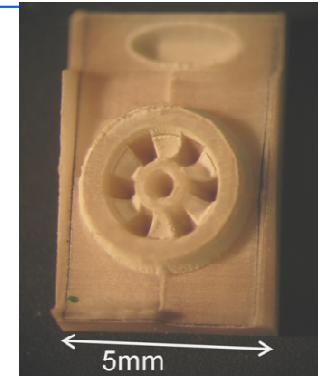
Picosecond

Acc.V Spot
20.0 kV 5.2



Nanosecond machining of Y-TZP ceramic

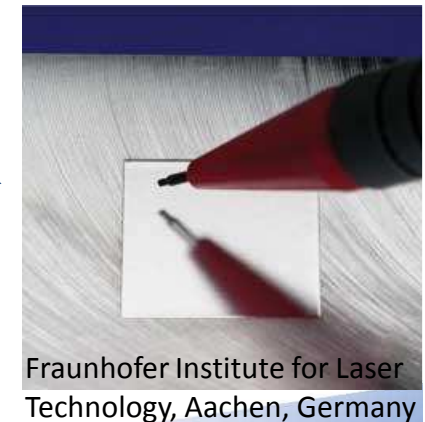
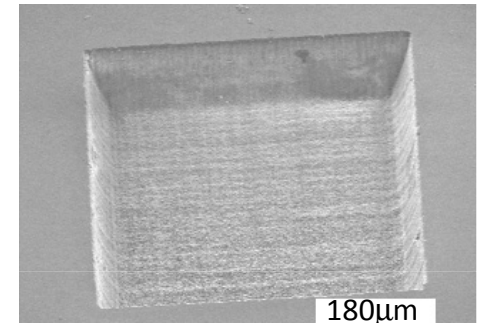
Acc.V Spot Magn Del WD
20.0 kV 5.2 2000x 10.0 10.0



Single shot machining of BK7 glass 160 μ J, 150fs

Laser machining of optical surfaces – optimal pulse length?

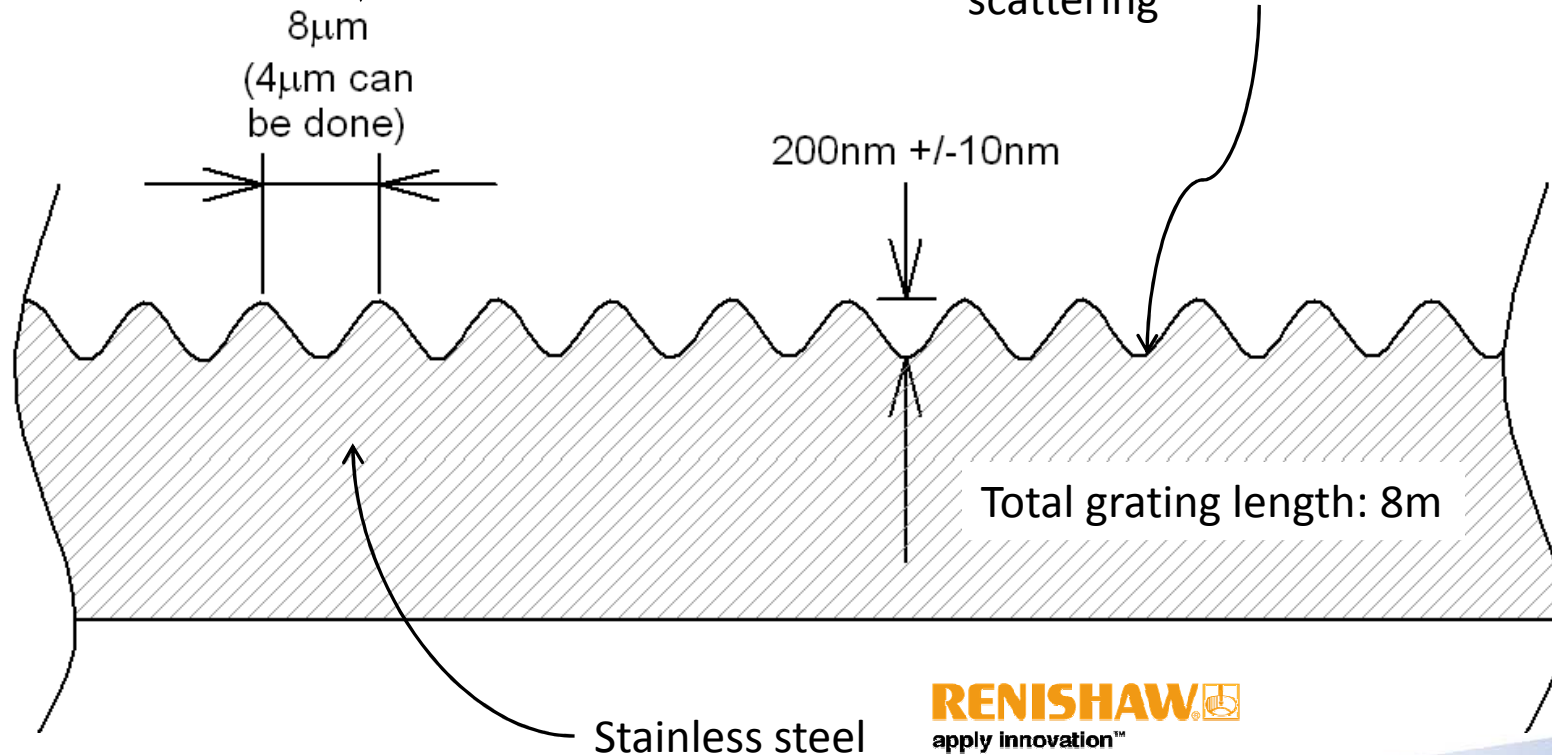
- Picosecond and femtosecond lasers give minimal heat affected zone
 - Ideal for particular materials e.g. glass, ceramics
 - Minimal cracking or other thermal damage
 - Excellent control over ablation depth
- However, lasers still relatively expensive and complex
- Also, do not generate optical quality surfaces
 - For optical surface manufacture, use longer pulses →
 - Nanosecond, millisecond, microsecond
 - Controlled surface melting



Requirement for manufacture of optical grating structure

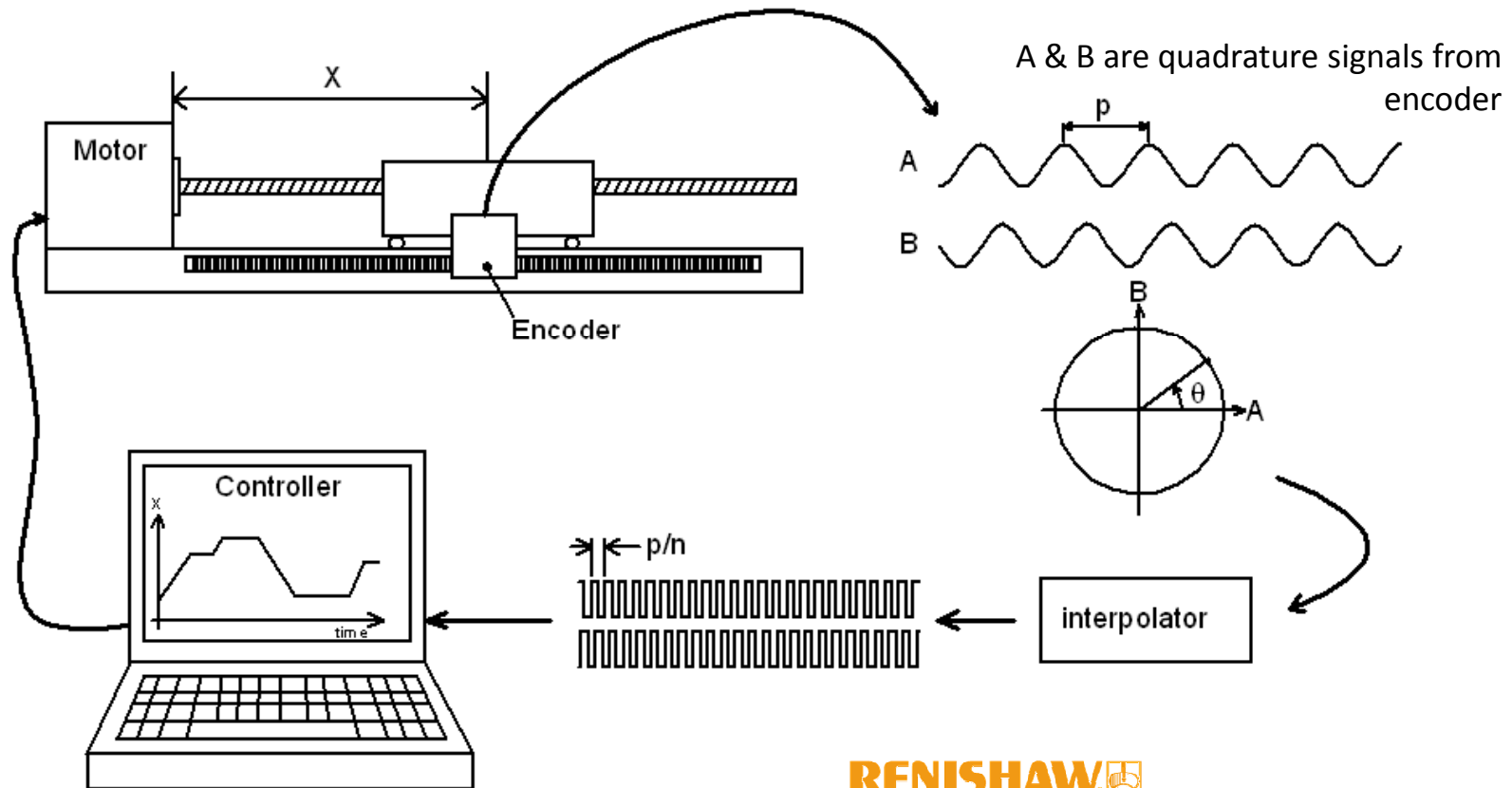
Tolerance over long grating $\pm 5\mu\text{m}/\text{m}$

Smooth surface on sinusoidal
oscillations needed to minimize
scattering



Encoders

Convert linear or rotary motion into electrical signals for feedback control



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Diffraction scale

Note sharp features on typical phase scale

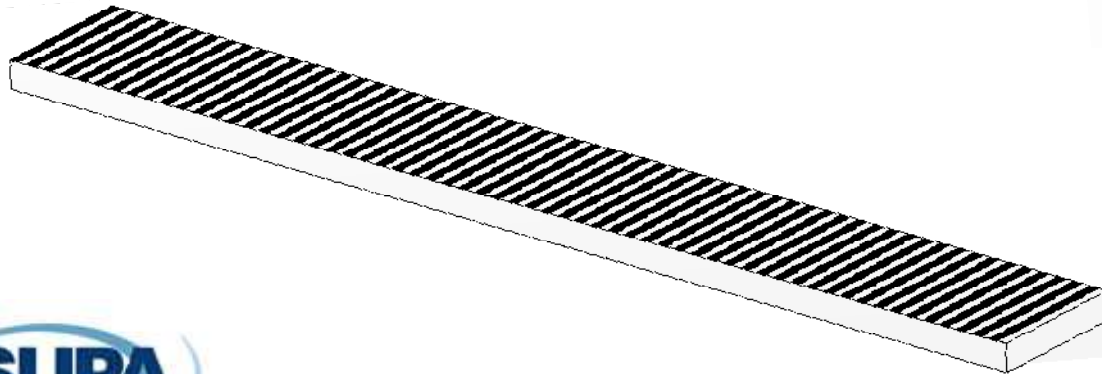
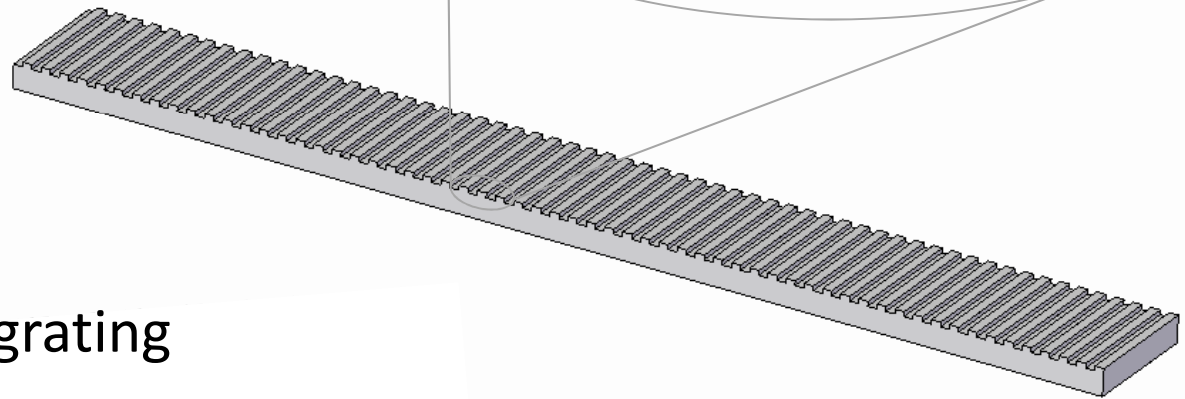
Precision encoder scale:

usually a long diffraction grating,
in this case:

a phase grating

As opposed to:

amplitude (Ronchi) grating

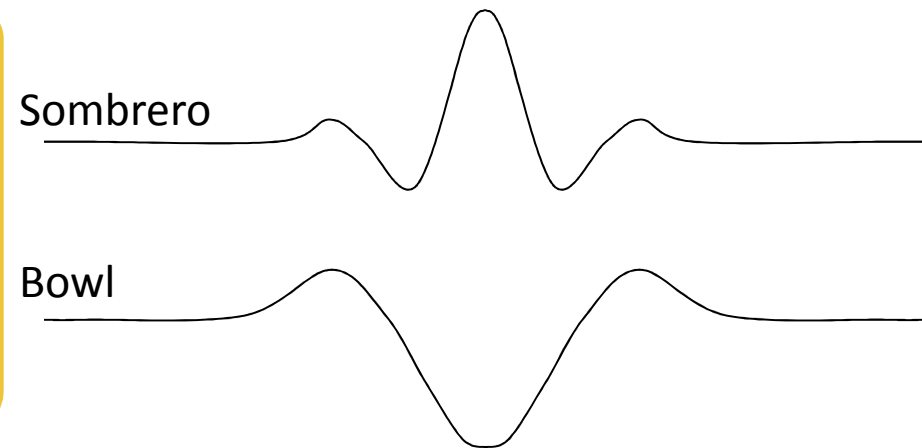


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Melted features

Experimental results

Material A	→	Single pulse per feature
Material B	→	>20 pulses per feature
CO ₂	→	Sombrero
Air	→	Bowl
Ar	→	Bowl

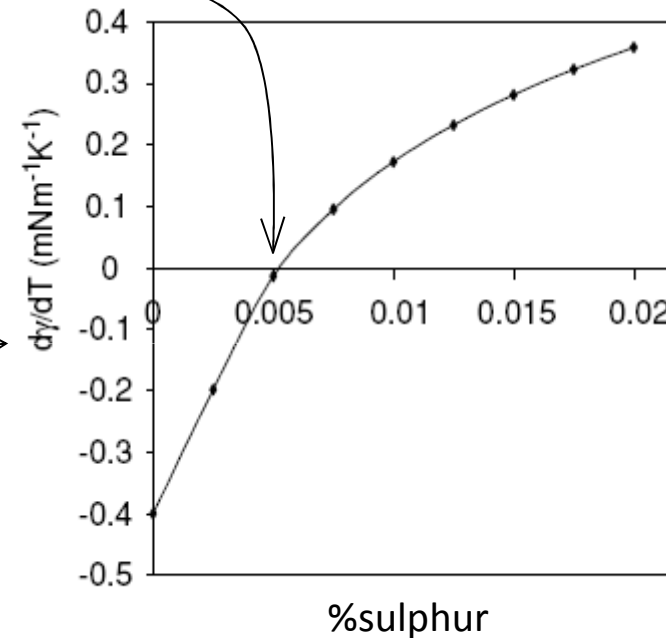


- 1) Marangoni effect. Surface tension forces: proportional to thermal forces divided by viscous forces
- 2) Thermo-capillary motion: buoyancy, density changes, thermal currents
- 3) Chemi-capillary motion: diffusion across surface, chemical reactions

Surfactant concentration

Materials with critical surfactant concentration can show little surface disturbance with laser pulse interaction.

Coefficient of surface tension with temperature drives surface forces

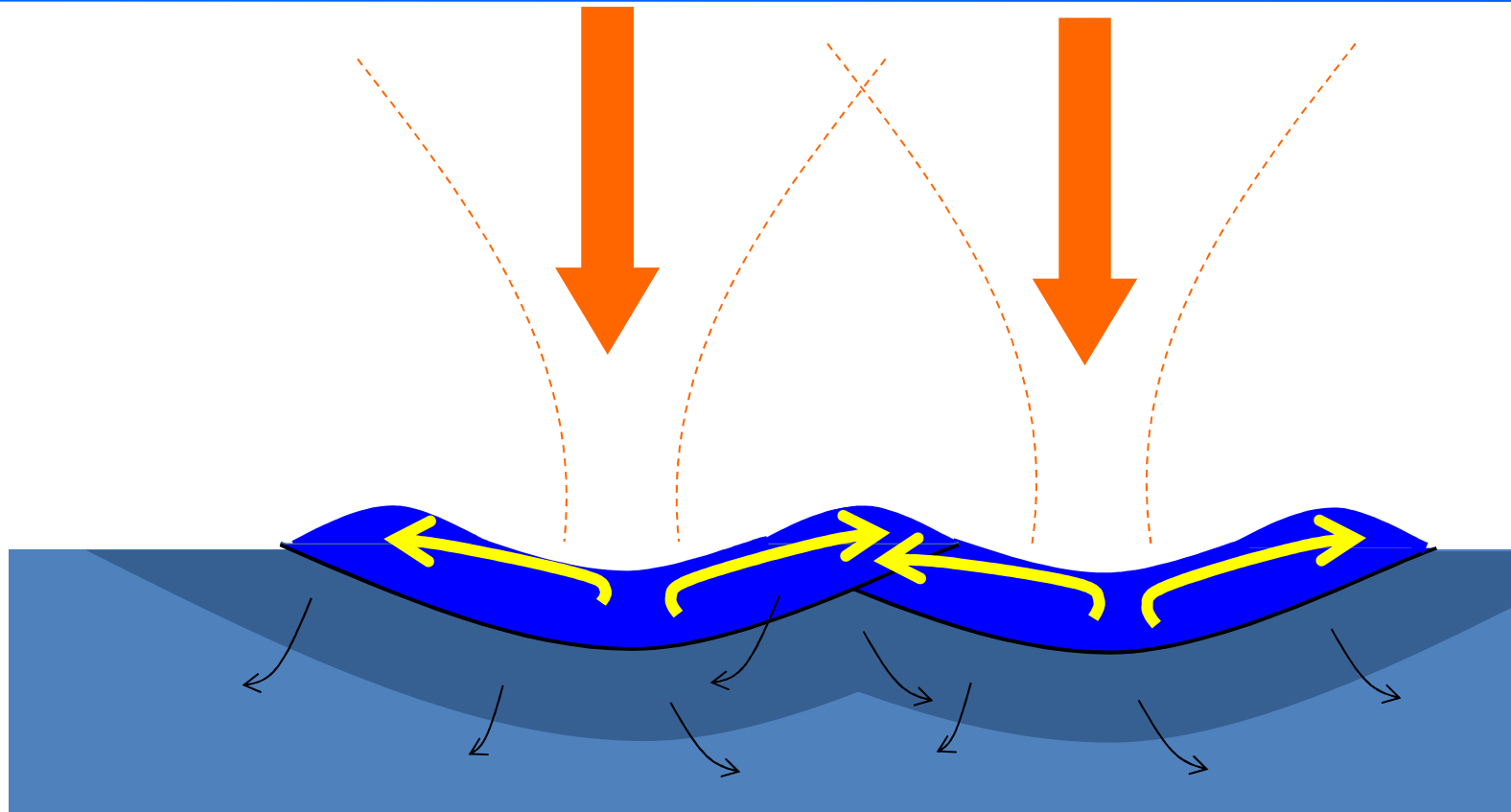


Many elements can act as surfactant:
oxygen,
sulphur,
phosphorous
and more

Thermal coefficient of surface tension
behaviour with sulphur concentration

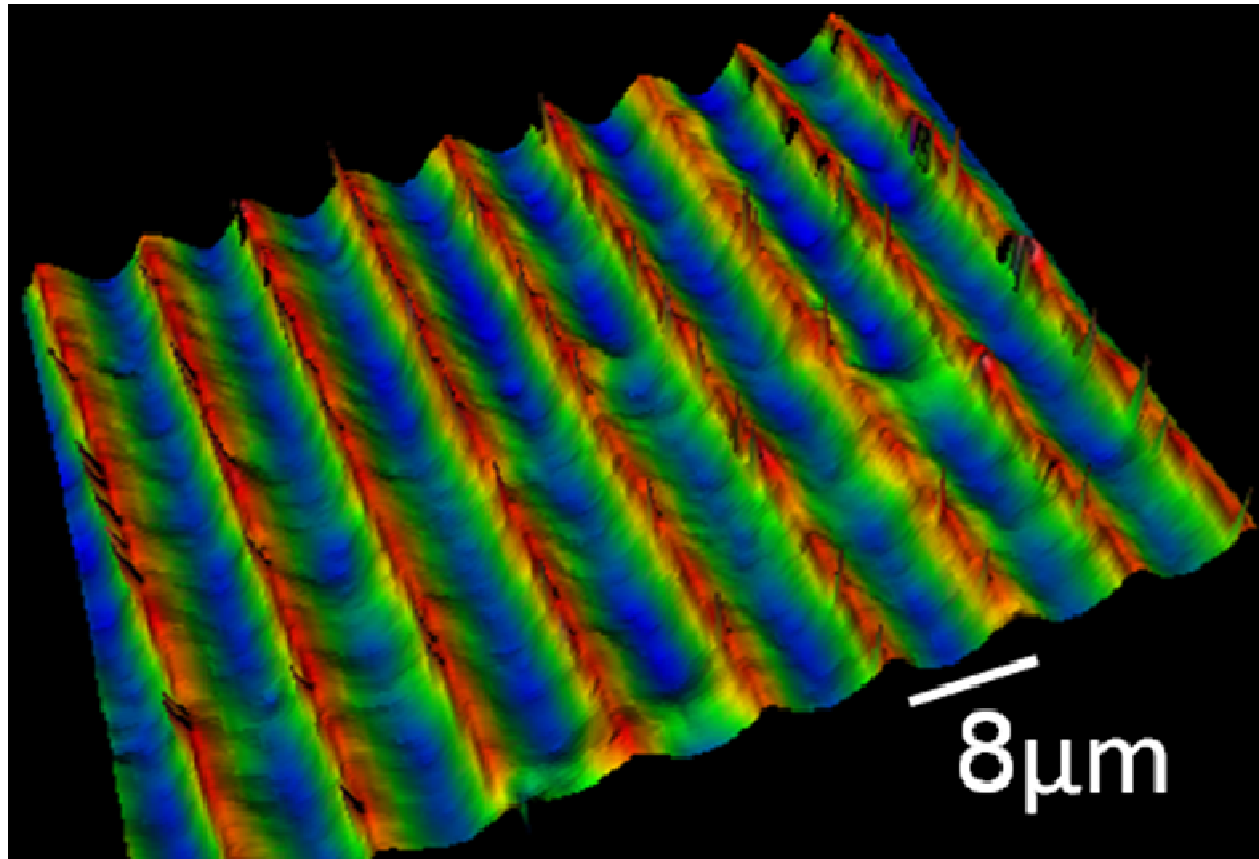
Y. Su, Z. Li, K. C. Mills
J.Mater.Sci. 40(2005)2201-2205

Generation of grating

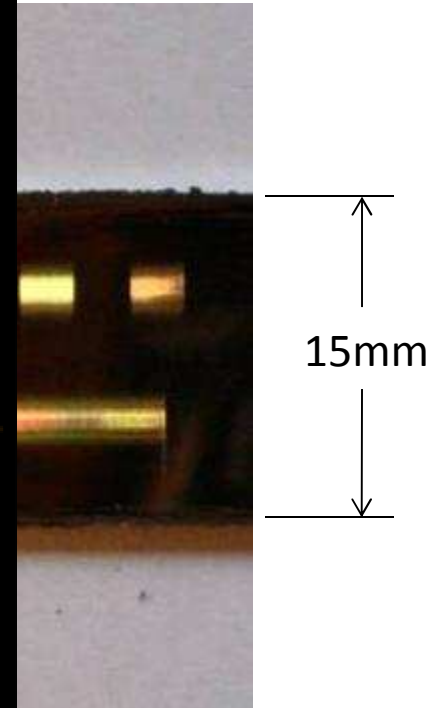


- Stainless steel
- Molten material
- HAZ, Temperature gradient
- Liquid/solid interface
- Convection fluxes

Results: diffraction grating by laser melting



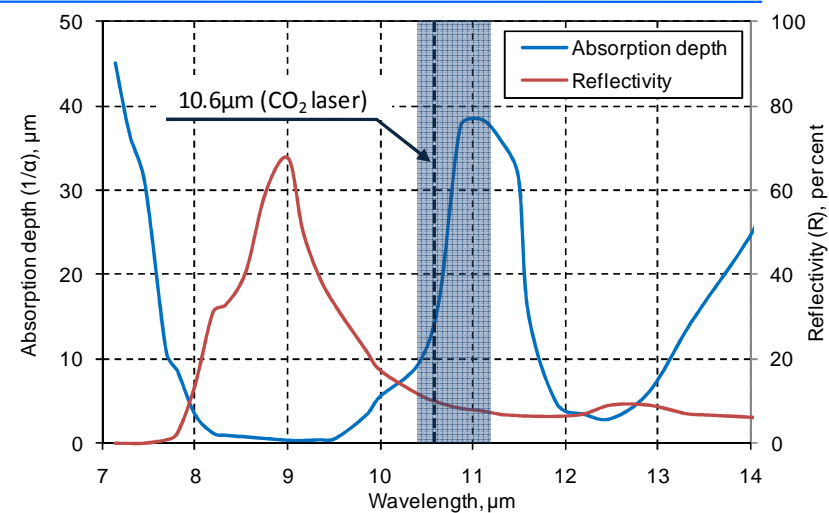
8μm period reflective phase grating
Depth of feature 200nm±10nm



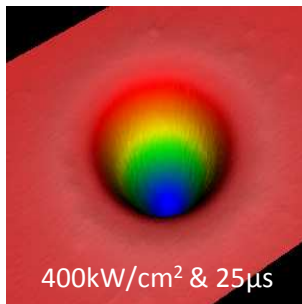
Shown illuminated by domestic
tungsten filament bulb

Glass optics: CO₂ laser process

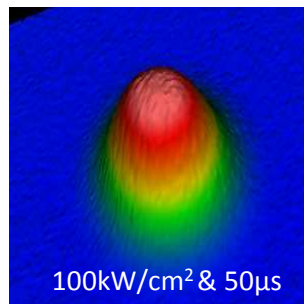
- highly transparent between 0.3 – 2.2μm wavelength ($T > 90\%$)
- strong absorption at 10.6μm wavelength
- only optical glasses with low CTE (e.g. fused silica) can be extensively machined with a CO₂ laser at room temperature without material cracking
- single laser pulses produce deformations at the glass surface



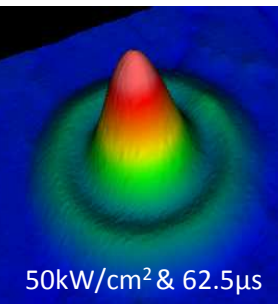
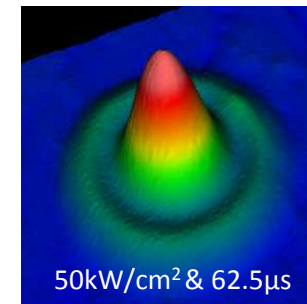
Crater generated in fused silica
(HPFS[®]7980, Corning)



Bump and ring generated in
Borofloat[®]33 (Schott AG)



Sombrero generated in lead-silicate glass
(SF57, Schott AG)

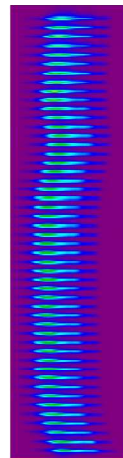
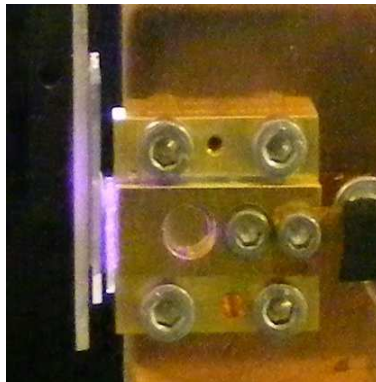


Application of CO₂ laser process

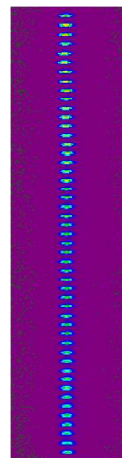
- Laser cutting and polishing for generation of optical components
 - Precision laser cutting of silica using pulsed CO₂ with optimised laser conditions
 - Smoothing of surface with optimised cw CO₂ laser re-melting

Recent example –Correction and slow axis collimation of 49 single mode diode laser on one bar

SLOW AXIS NEAR FIELD IMAGE

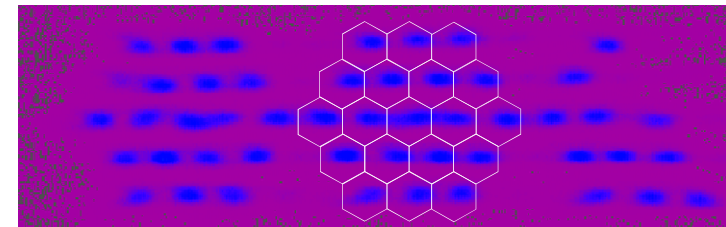
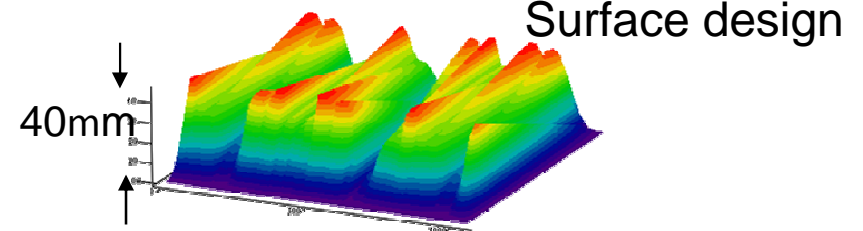


UNCORRECTED



CORRECTED

Conversion of linear array into
hexagonal packing

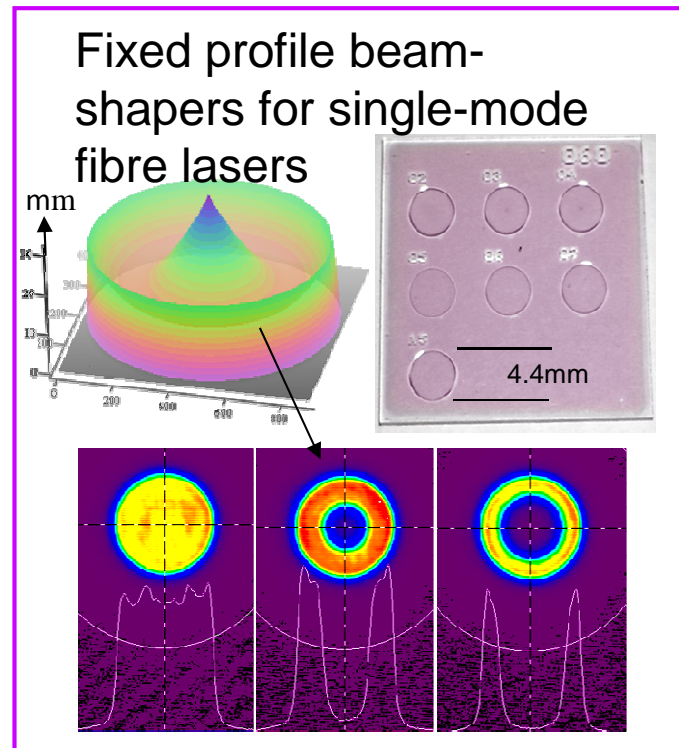


CO₂ laser process – commercial exploitation

**PowerPhotonic Ltd, Fife is the HWU
spin-out, exploiting our original research**

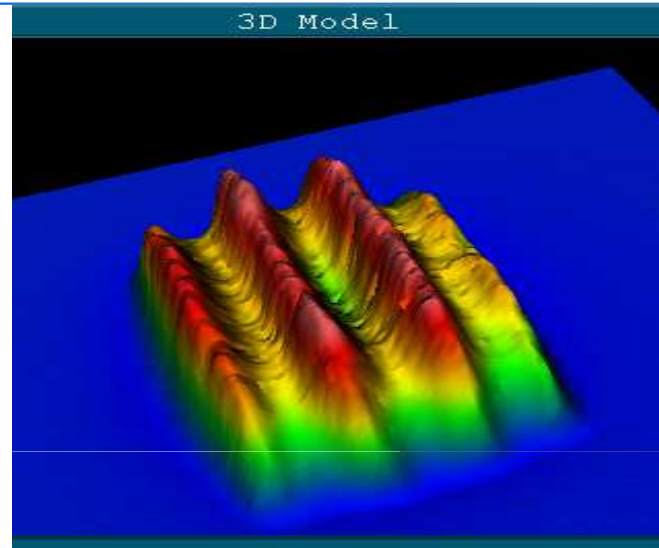
- Directly-written optical surfaces to 1/10 wavelength accuracy
- Wafer scale processing, using several proprietary laser tools
- Custom correction optics for improving diode laser brightness
- Collimation array optics for diode laser systems
- Beam shaping for close-packing, matching diode laser array beams into fibre optics
- Beam shaping for conventional lasers, and for optical interconnects

*Currently world leading in custom refractive
micro-optics, with unique products*

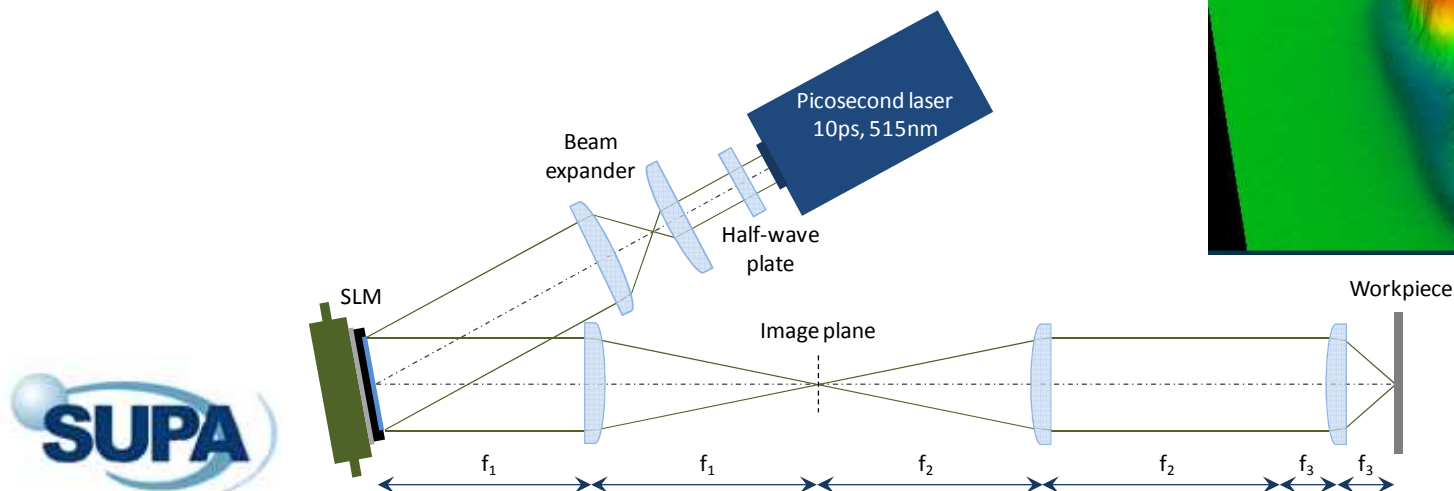
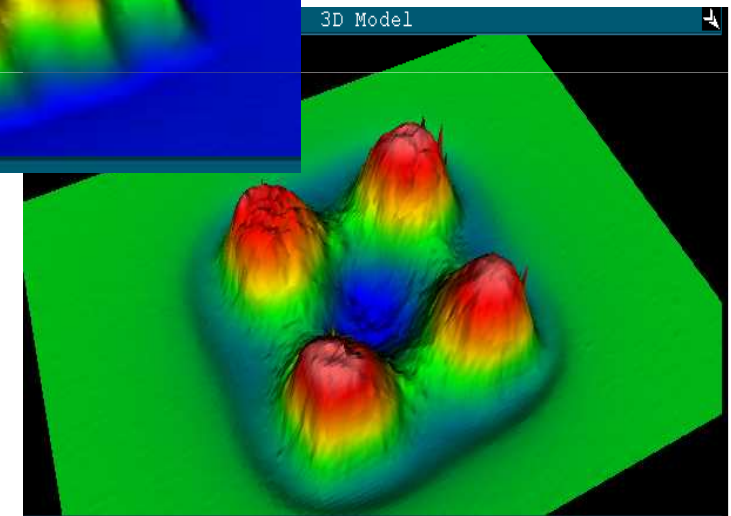


Also demonstrated surface profiling with ps laser on glass

Picosecond laser + liquid
crystal spatial light
modulator used with glass
(with absorbing layer) –
see poster P10

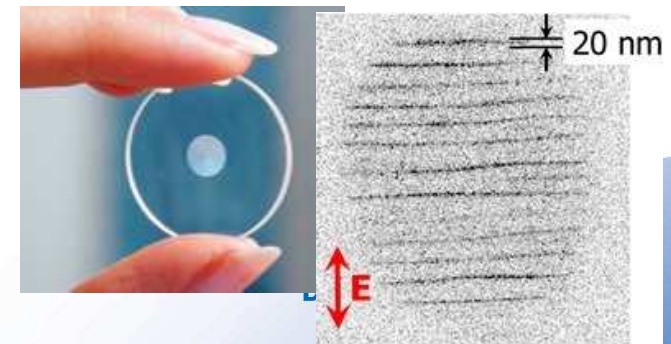
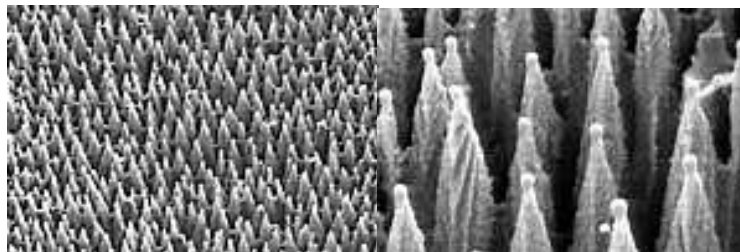
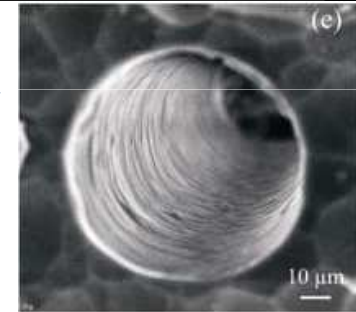
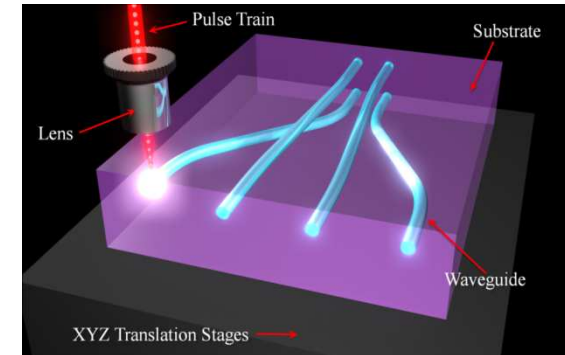


Raised structures
on borosilicate
glass



Additional optical fabrication techniques

- Refractive index modification
 - Waveguide writing
 - Grating writing
- Laser material modification + etching
 - Generation of buried channels
- Surface microstructuring
 - Nano-gratings (birefringent – e.g. waveplates, Kazansky)
 - Absorbing surfaces e.g. black silicon



Summary – micro-structuring of optical surfaces

- Highly localised melting processes required to provide optically smooth surfaces
 - Nanosecond (or longer pulses) better than ultrafast
- Surface profile can be controlled by exploiting Marangoni effect
 - Encoder gratings
 - Bespoke glass optics
- Combine with other laser-based processes (RI modification, laser+etching) for complete optical fabrication process

**Thank you for your
attention !**